



Istituto Nazionale
di Fisica Nucleare
TIFPA
Trento
Institute for
Fundamental
Physics and
Applications

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BRUNO KESSLER

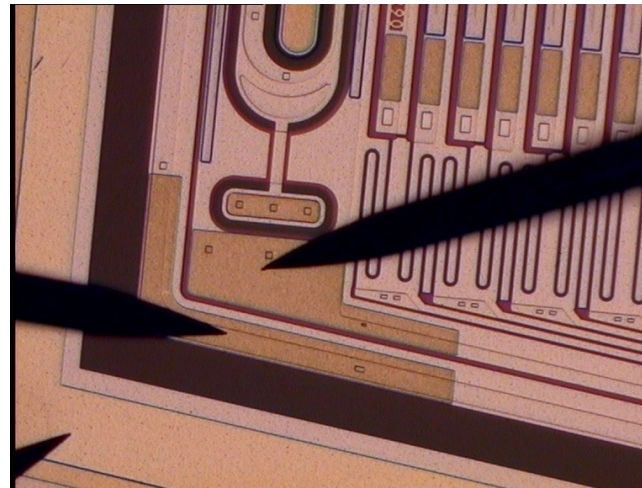

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TRIESTE

First productions of large area Silicon Drift Detectors for the eXTP Wide Field Monitor instrument: test results and yield assessment.

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iWoRiD - Lisbon - Rashevskaya Irina

The enhanced X-ray Timing and Polarimetry Mission (eXTP)

The enhanced X-ray Timing and Polarimetry Mission is a scientific space program that will look at X-rays coming from targets such as neutron stars, and black holes to study the state of matter in extreme conditions of density, gravity and magnetism.

The scientific payload of the mission consists of four main instruments, among which the **Wide Field Monitor** will observe the X-ray sky with

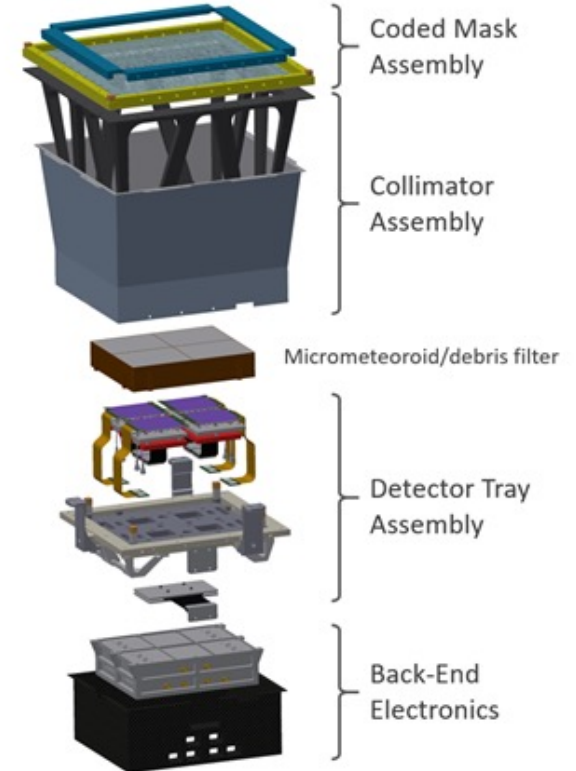
- a large field of view of **90°x30°**
- FWHM **angular** resolution better than 4.3 arcmin
- an **energy resolution** better than 500 eV FWHM at 6keV.

WFM consists of **6** coded-mask cameras, each made up of **4 Detector Assemblies (DAs)**, for a total of **24 Large-area Silicon Drift Sensors**

* See also Poster of Antonelli Matias



The enhanced X-ray Timing and Polarimetry mission will cost around three billion yuan (£340m) and is set to launch by 2025 (courtesy: Institute of High Energy Physics)



Other proposed missions STROBE-X and LEM-X

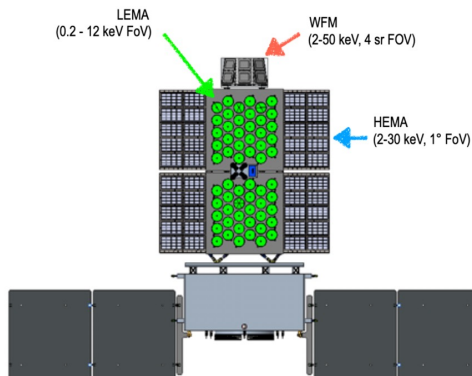
These sensors we are developing for eXTP have been adopted by other two proposed missions: Strobe-X, which was proposed to NASA for its probe class mission call, and the Italian LEM-X observatory on dark side of the moon.

STROBE-X Mission

STROBE-X is a probe-class **observatory** designed for X-ray timing and spectroscopy in the 0.2–30 keV band

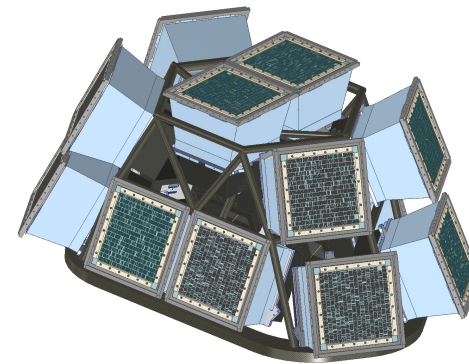
TIME-DOMAIN ASTROPHYSICS

Continuously surveying the dynamic X-ray sky with large duty cycle and high spectral and time resolution to characterize source behaviour over a vast range of time scales.

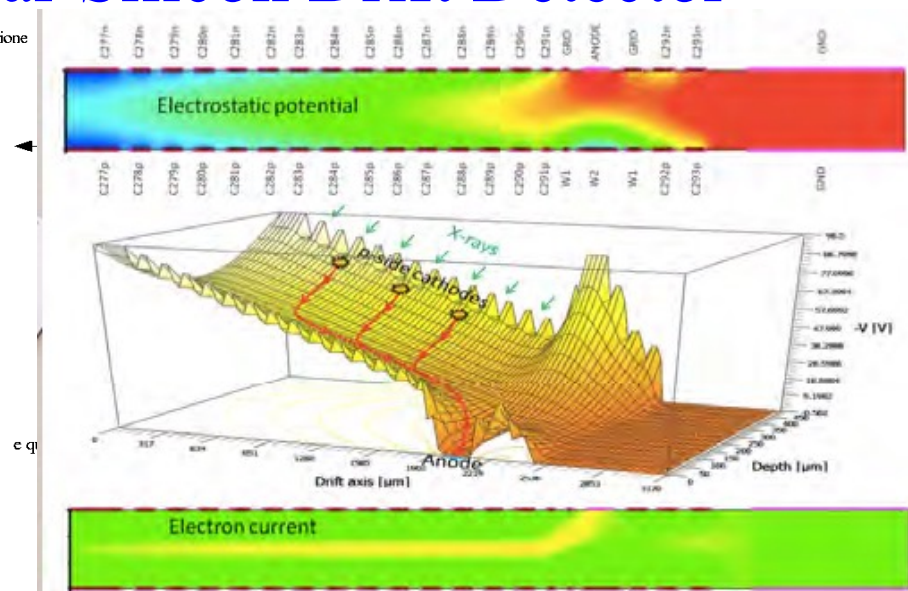
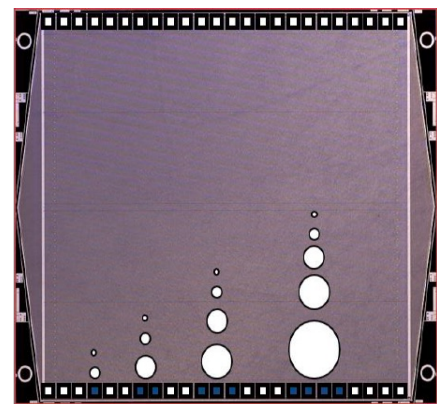
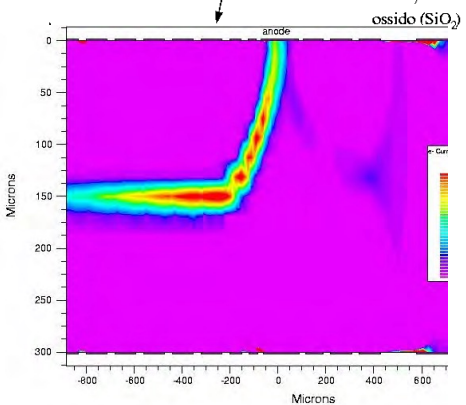
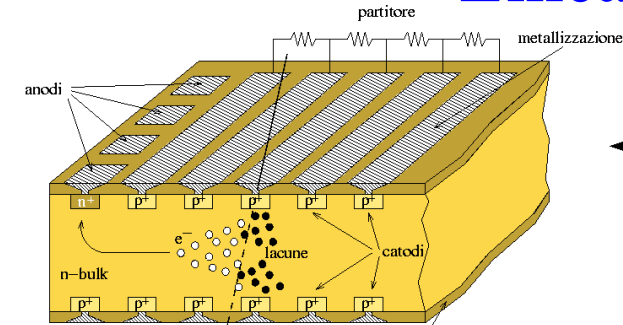


LEM-X

The **Lunar Electromagnetic Monitor in X-rays** (LEM-X) is a proposed **observatory** on the Moon surface for the detection of transients and the long-term monitoring of astrophysical sources across the whole observable sky in the 2 – 50 keV band.

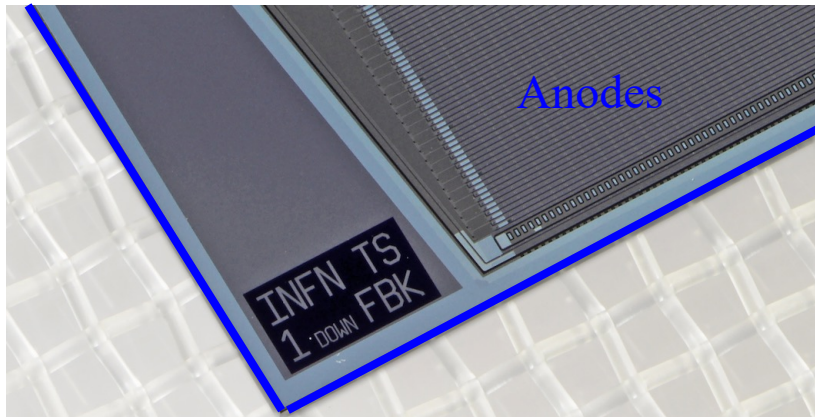
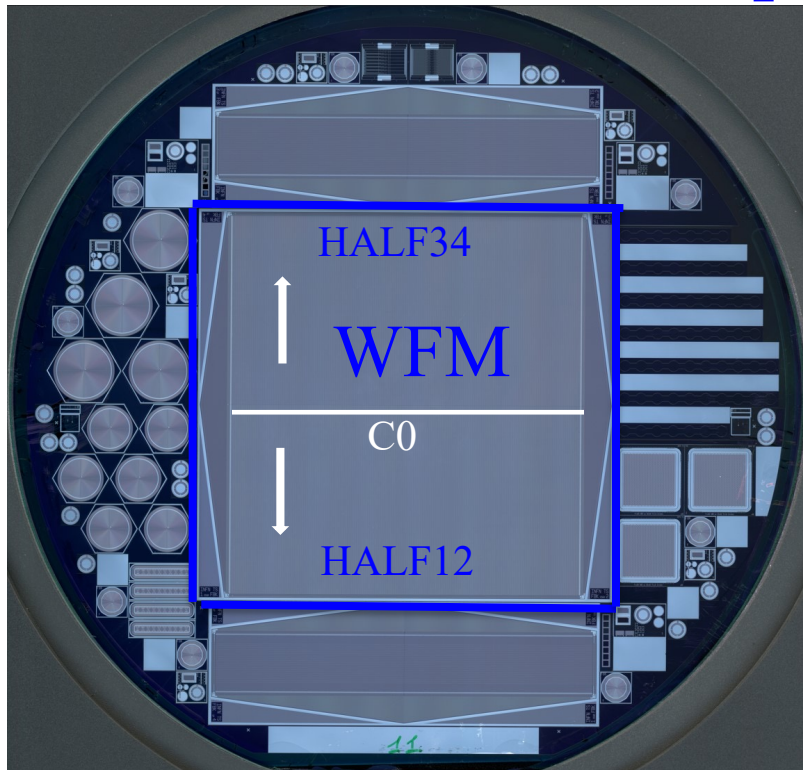


Linear Silicon Drift Detector



- p-type implants on both side of silicon with integrated voltage divider
- linear electric field from a high voltage at the central cathode to low voltage at the edges of the detector
- the line of n-type readout anodes
- electron cloud, created by charge particle, drifts and diffuses laterally
- The central anode gives us the x coordinate
- the width of the cloud gives as the y coordinate
 - large sensitive area
 - small readout anodes with low capacitance
 - reduced number of readout channels.

Sensor production



WFM layout

- two symmetrical drift regions HALF12 and HALF34 with one high voltage cathode CO, each one defined by 292 p-type cathodes implanted on both sides of the wafer
- the readout n-type anodes, organized in two arrays along opposite ends of the detector.

The challenge is to produce large area sensors with low leakage current and good yield

FBK Production

- Si wafer: 6", 450 um thick, float-zone, n-type
- Resistivity: 6.5-10 kΩcm
- Processing: double-sided, FBK proprietary **leakage reduction steps (gettering)**
- Batch : **WFM221** 15 wafer – 15 sensors
WFM231 20 wafer – 20 sensors

Sensors Parameters

Geometrical dimensions	$77.08 \times 72.42 \text{ mm}^2$
Active volume	$64.90 \text{ mm} \times 70.18 \text{ mm} \times 450 \text{ }\mu\text{m}$
Number of anodes	384 per half
Anode pitch	169 μm
Anode capacitance	$\approx 90 \text{ fF}$
Drift field	360 V/cm (Bias of 1.3 kV)
Drift speed	$5 \times 10^5 \text{ cm/s @ } 20 \text{ C}$, $7.6 \times 10^5 \text{ cm/s @ } -26 \text{ C}$
Leakage current (BOL)	$< 36 \text{ pA/anode (600 pA/cm}^2)$
Spatial resolution	$< 25 \text{ }\mu\text{m (anode) } < 6 \text{ mm (drift)}$
Operative temperature	- 26C

Specifications

- I lim 600 pA/cm^2 $36 \text{ pA/ anode @ } 20\text{C}$
- Less than 2% of defective anodes

Class A

$>98\%$ of Anodes in SPEC

Class B

one half of sensors with $>98\%$ of Anodes in SPEC

another half of sensors with 72-97 % of Anodes in SPEC

Class C

with 72-97 % of Anodes in SPEC

Class D

very high cathode current

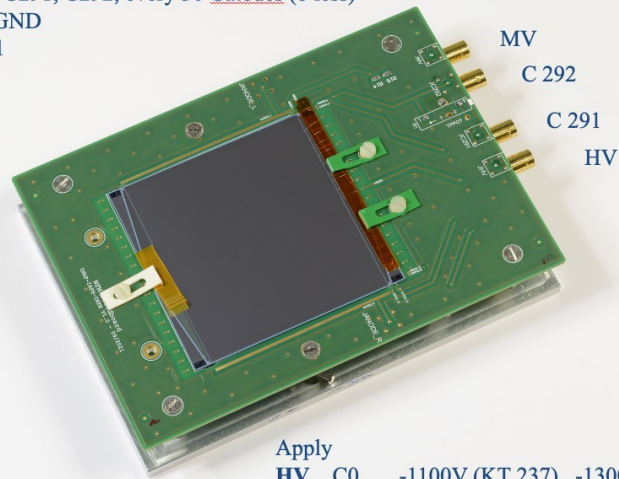
Test - PC Board Probe Station

BOND

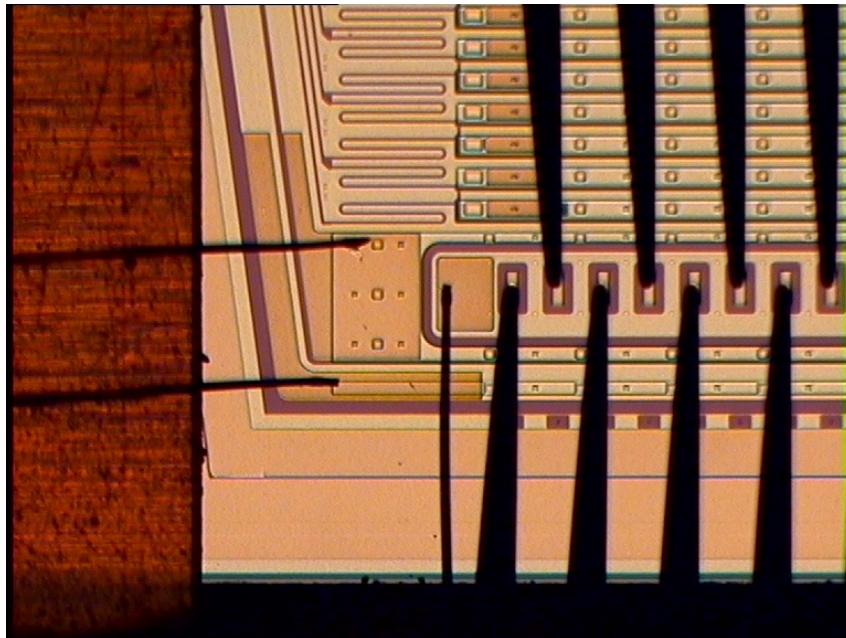
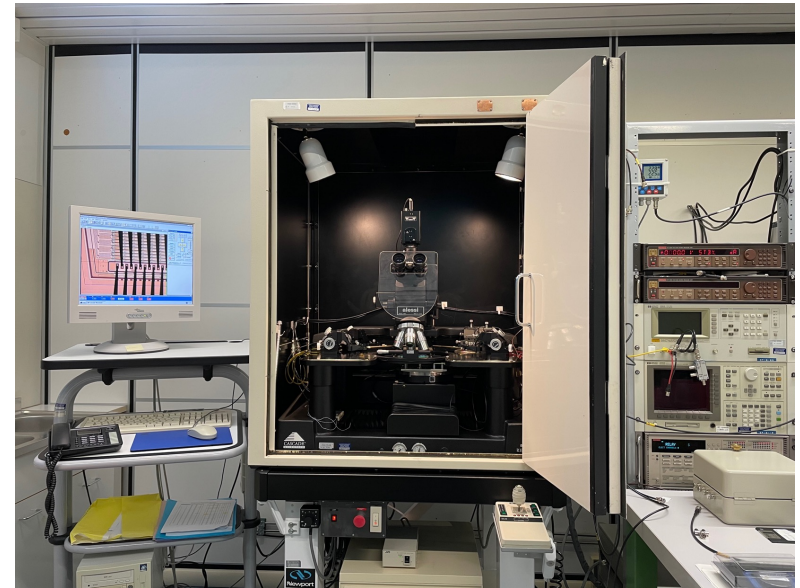
P&N side - C0, C291, C292, every 30 Catodes (o less)

N side - Grid, GND

P side - W2, W1



Apply
HV C0 -1100V (KT 237) -1300 (KT248)
MV W2 -70V HP4141B

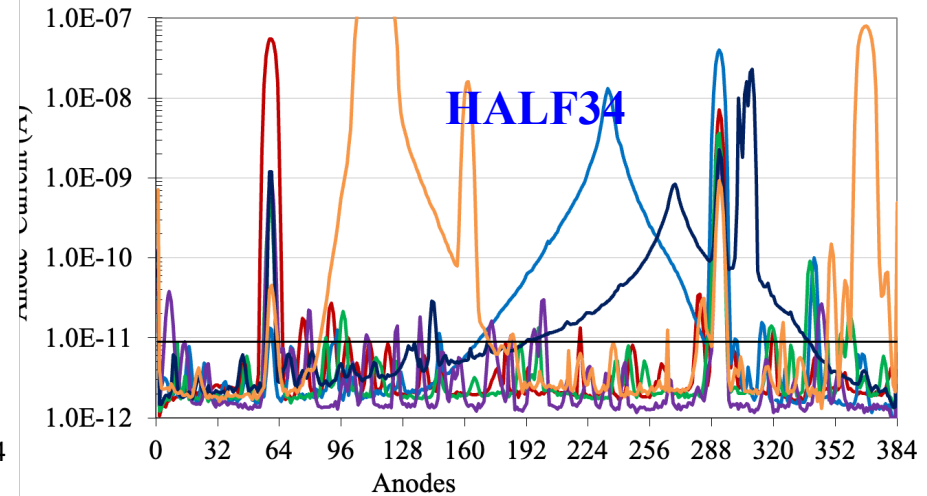
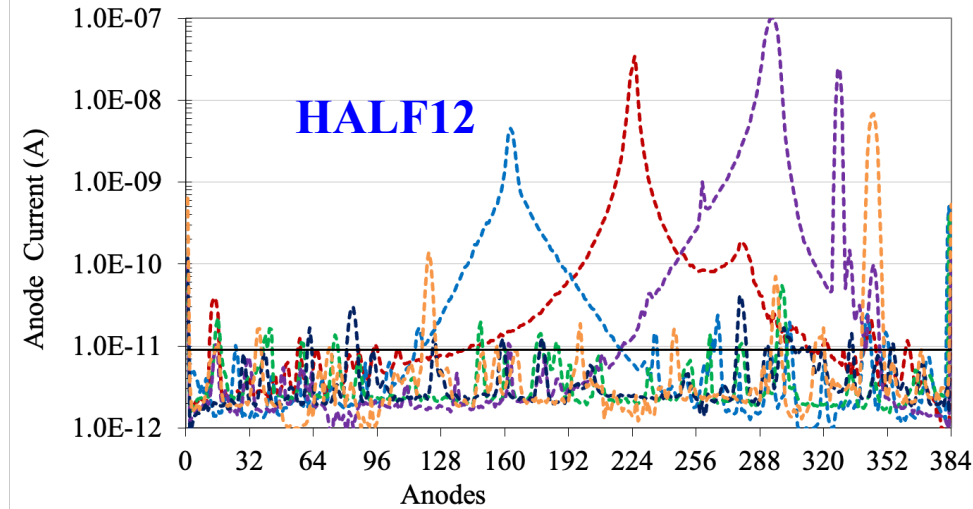


384 Anodes with 169 um pitch

The automatic scan is performed with the **50-needles ProbeCard**. There are exactly 8 positions of the probecard for testing all the anodes. In the first position anodes 1-48 are measured with two last needles connected to GND. Then for 6 positions of the probecard **48 central anodes with two outer needles connected to GND** are measured. In the last position the last 48 anodes are tested with two first needles connected to GND.

Scans are performed for two half-detectors **HALF12** and **HALF34**.

Sensors Production - WFM 221 (2022) 15 sensors



Class A	0 sensors
Class B	2 sensors
Class C	4 sensors
Class D	9 sensors

For the next **WFM231** Batch FBK applied

- special procedure of handling
- increased robustness (more processing steps) and surface protection of the side not under processing

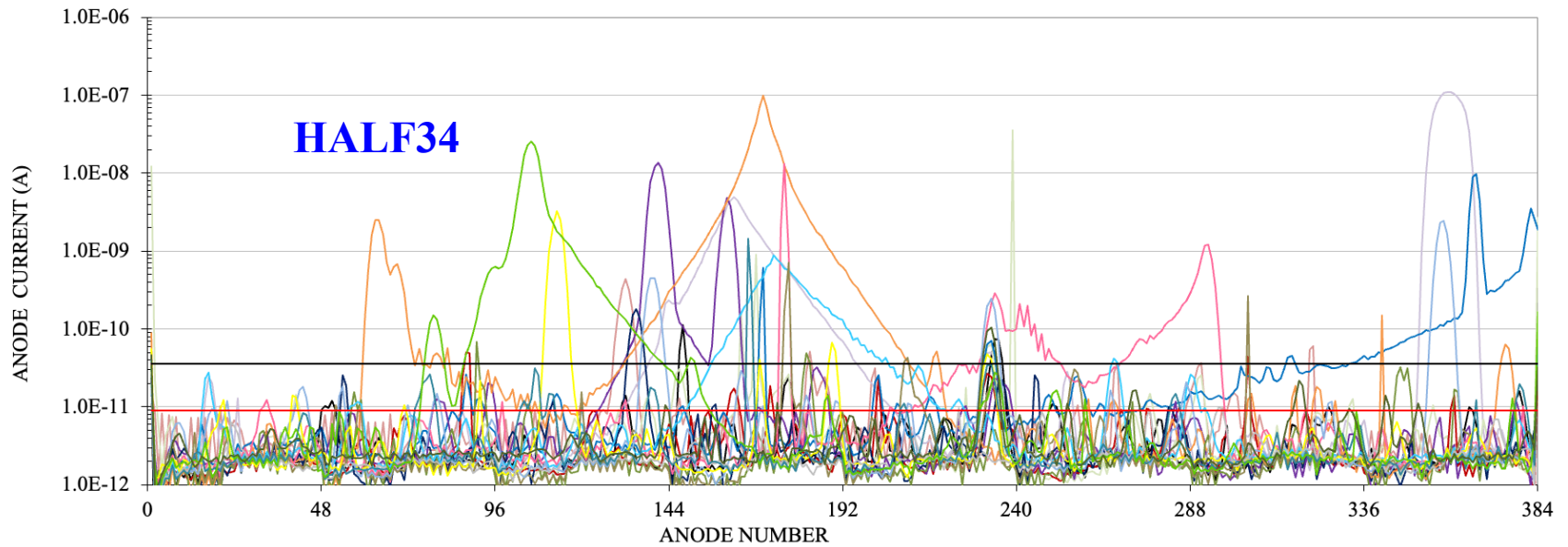
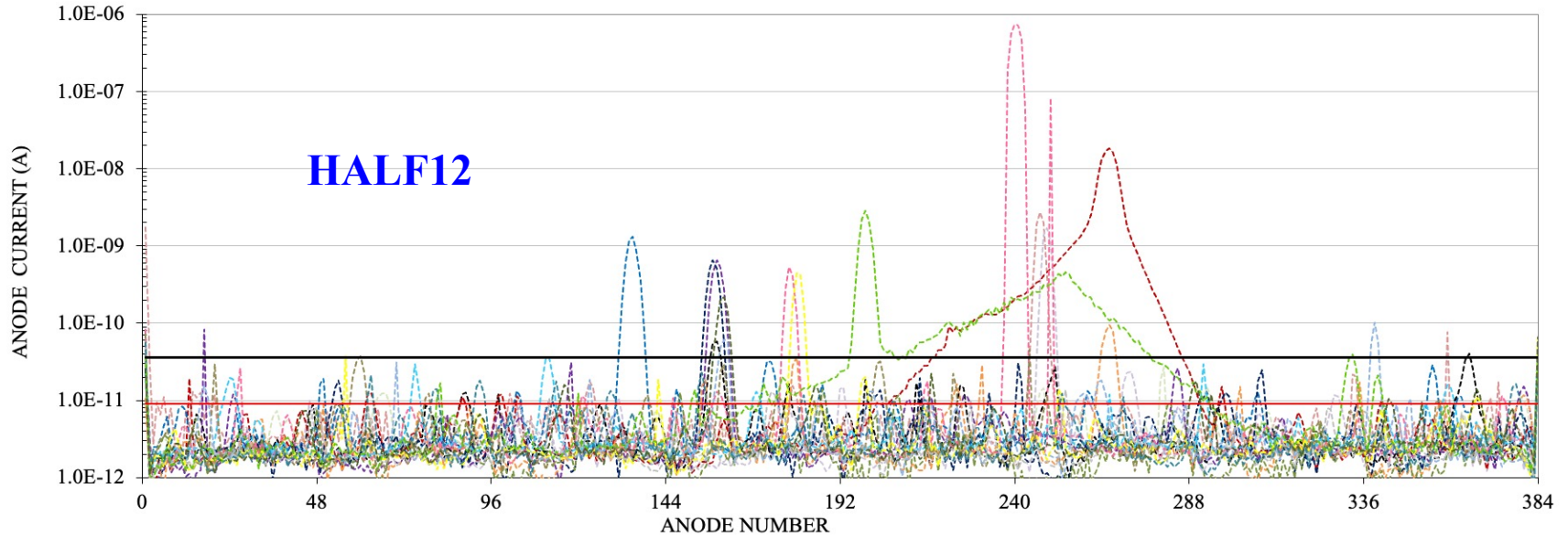
Sensors Production – Batch WFM 231 (2023) 20 sensors

		WFM															
		pA	A	pA/cm2													
		I limits	35.82	3.58E-11	600.0												
		LOT	WAFER	I min	I limits	I max	< I Anodes >, I Anodes < I limits			GOOD	BAD	Yield	A	B	C	Mec	TOT
				A	A	A	A	pA	pA/ cm2	N	N	%	8	9	2	1	20
							20C	20C	20C								
1	WFM231 23/10/2023	1	DOWN12	4.78E-13	3.58E-11	5.84E-11	3.77E-12	3.8	63	378	6	98%	1				
			UP34	7.58E-14	3.58E-11	1.14E-10	3.26E-12	3.3	55	377	7	98%					
			TOT	7.58E-14	3.58E-11	1.14E-10	3.51E-12	3.5	59	755	13	98%					
2	WFM231 23/10/2023	2	DOWN12	1.60E-12	3.58E-11	2.73E-09	4.52E-12	4.5	76	375	9	98%		1			
			UP34	1.20E-12	3.58E-11	4.34E-10	4.56E-12	4.6	76	371	13	97%					
			TOT	1.20E-12	3.58E-11	2.73E-09	4.54E-12	4.5	76	746	22	97%					
3	WFM231 23/10/2023	3	DOWN12	8.25E-13	3.58E-11	1.73E-09	3.26E-12	3.3	55	378	6	98%		1			
			UP34	8.04E-13	3.58E-11	1.10E-07	4.54E-12	4.5	76	304	80	79%					
			TOT	8.04E-13	3.58E-11	1.10E-07	3.83E-12	3.8	64	682	86	89%					
4	WFM231 23/10/2023	4	DOWN12	1.08E-12	3.58E-11	4.97E-11	3.15E-12	3.1	53	382	2	99%	1				
			UP34	1.06E-12	3.58E-11	3.55E-08	4.44E-12	4.4	74	376	8	98%					
			TOT	1.06E-12	3.58E-11	3.55E-08	3.79E-12	3.8	63	758	10	99%					
5	WFM231 25/10/2023	5	DOWN12	5.80E-13	3.58E-11	1.83E-08	4.40E-12	4.4	74	314	70	82%		1			
			UP34	4.13E-13	3.58E-11	4.98E-11	3.22E-12	3.2	54	380	4	99%					
			TOT	4.13E-13	3.58E-11	1.83E-08	3.76E-12	3.8	63	694	74	90%					

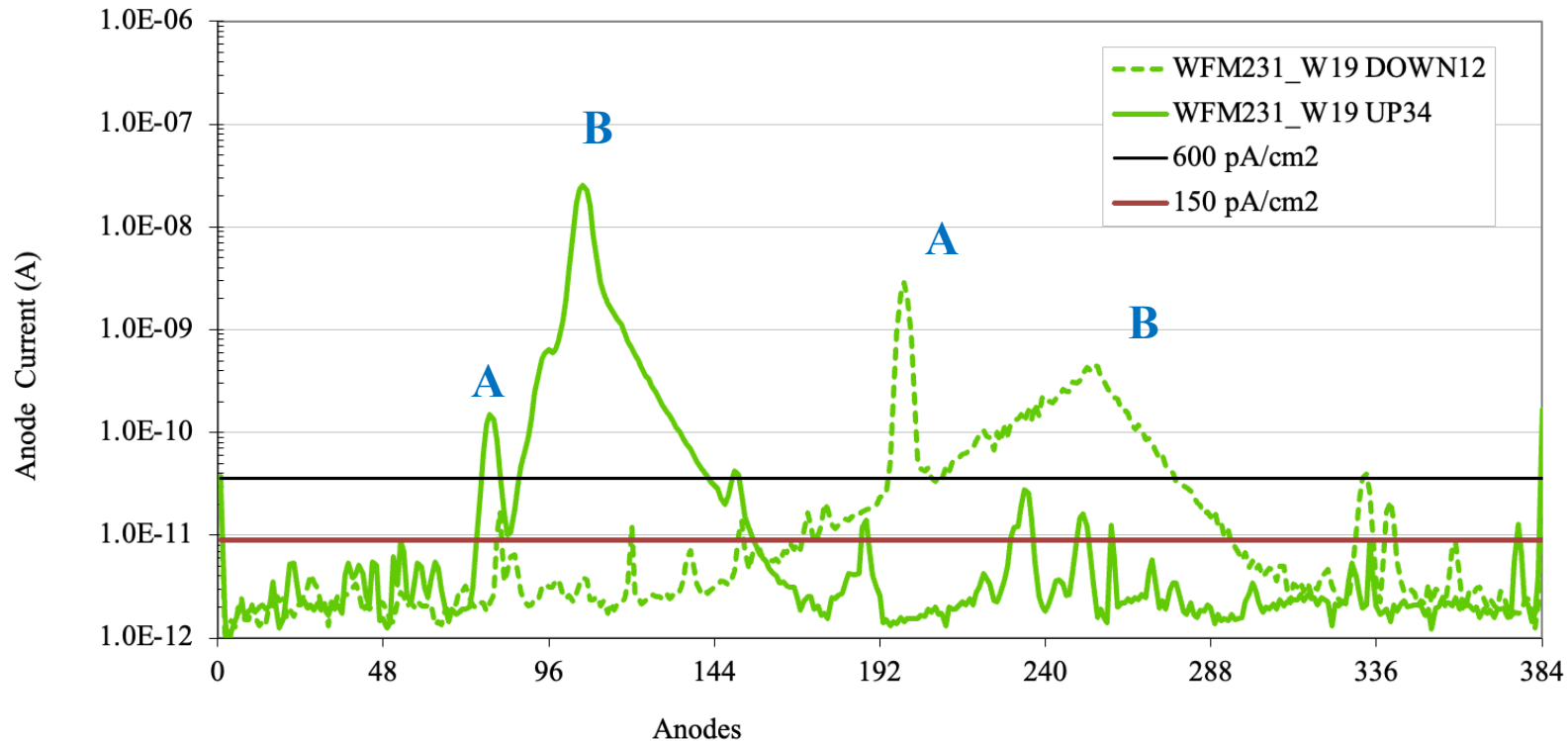
< I > = 50 - 70 pA/cm² (3 - 5 pA/anode)

- Class A** 8 sensors (yield 40%)
- Class B** 9 sensors
- Class C** 2 sensors
- Class D** 1 sensor

WFM 231 Anode Scan of 19 Sensors



WFM 231 W19



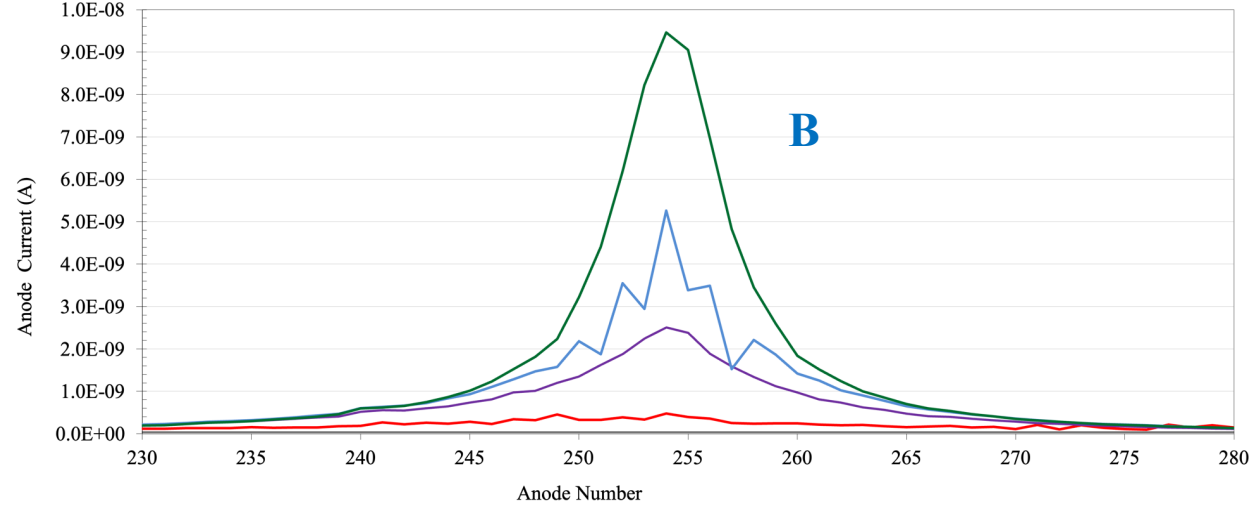
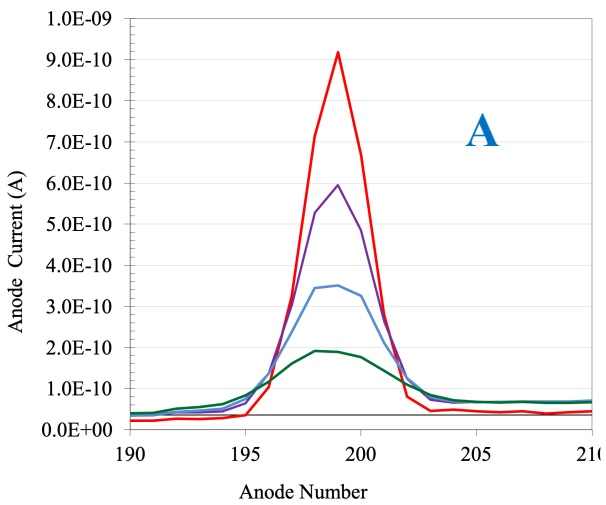
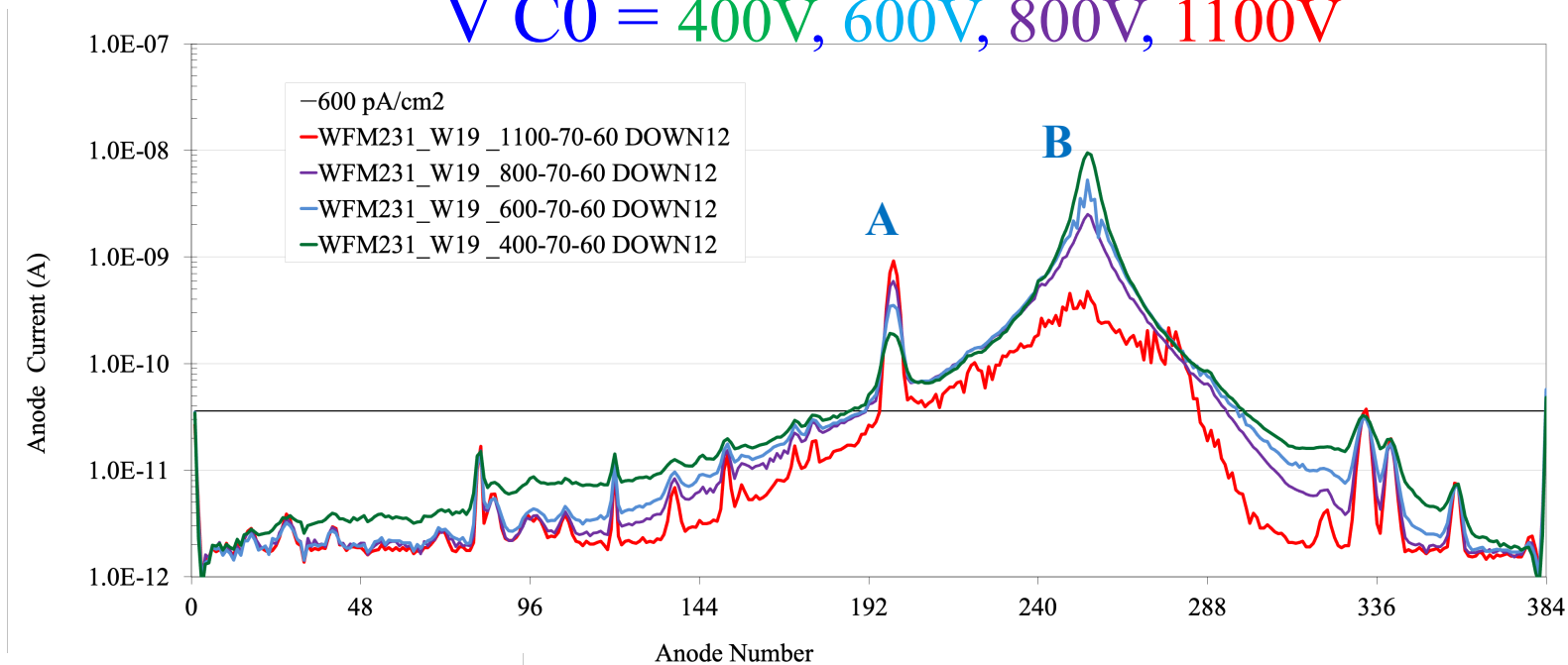
Two types of defects

- **A** “Normal” peak, involving 8-10 Anodes
- **B** “Triangle” peak, involving 80-150 Anodes

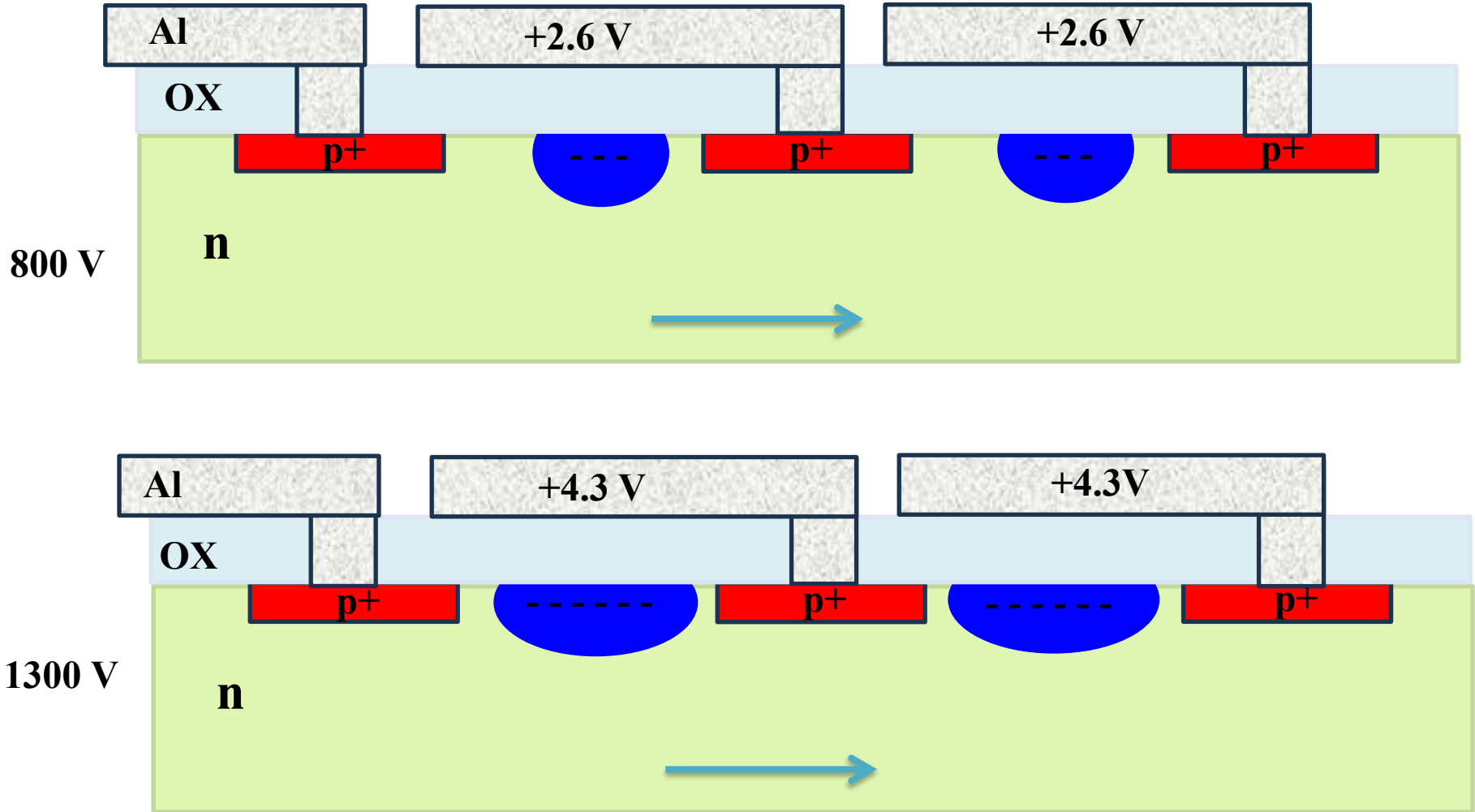
Defects of type A involve a limited number of anodes. The current generated by defects A diffuses while drifting toward the anodes the same way the signal charge does.

WFM 231 W19 SCAN

V C0 = 400V, 600V, 800V, 1100V

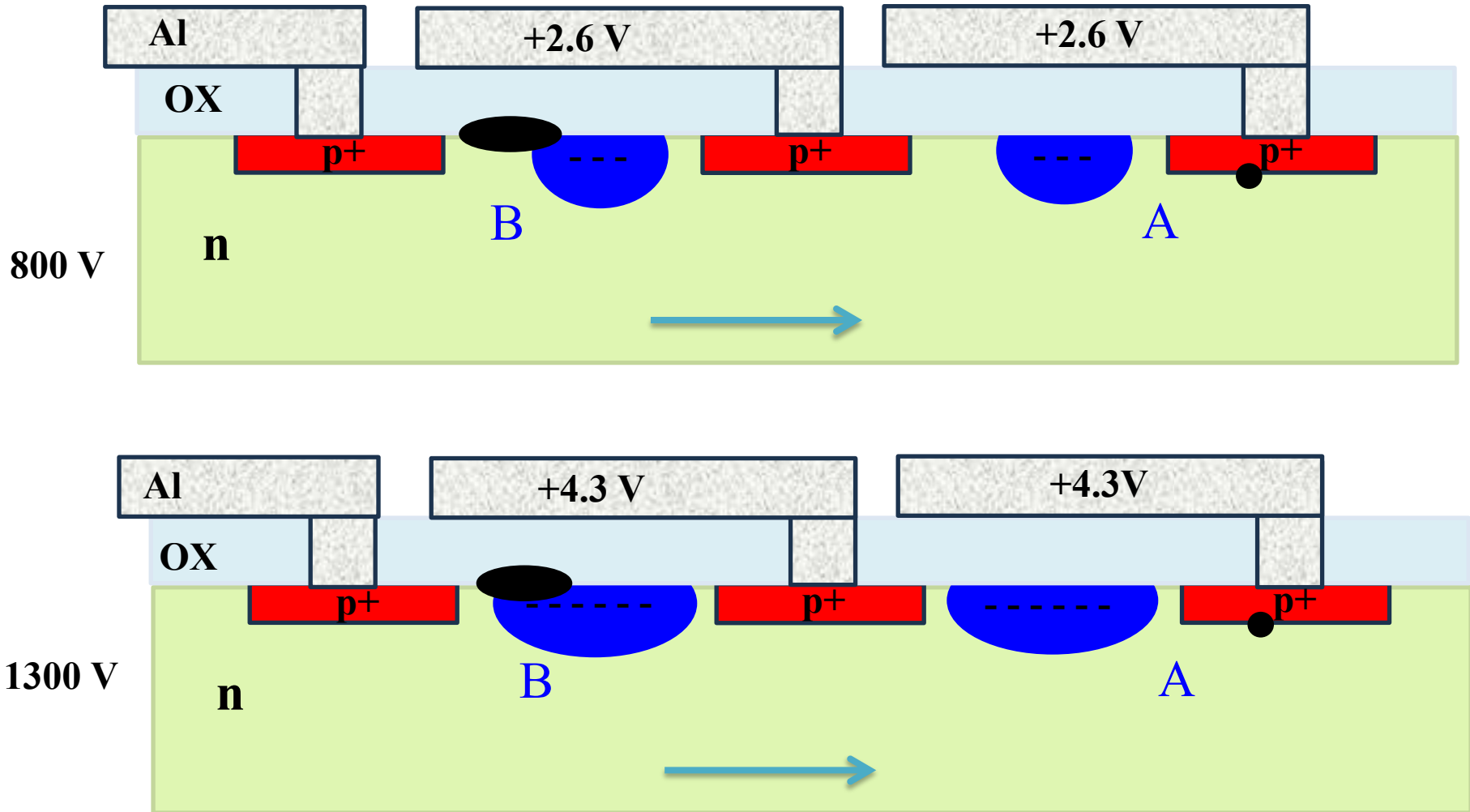


WFM 231 W19 Defects A and B



The positive field plate attracts more electrons in accumulated zone and extend laterally.

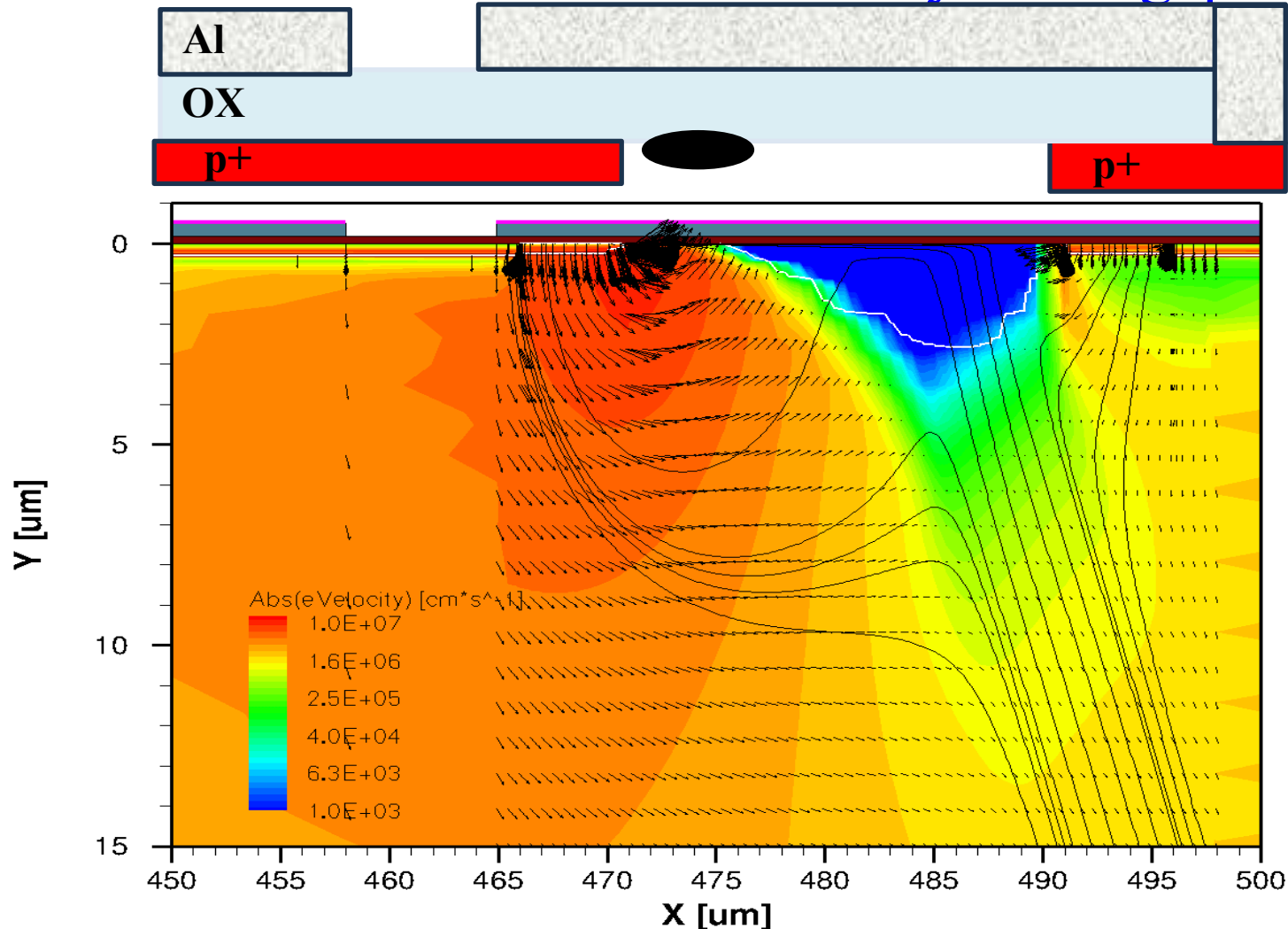
WFM 231 W19 Defects A and B



Defect B: extended defect in the Si-Oxide interface. Defect B enters gradually in the non depleted region so its efficiency at generating leakage current decreases.

Defect A: single-point defects in a Bulk.

Simulations. Electron Velocity in the gap region.



B

Electrons generated in proximity of the silicon-oxide interface are driven toward the non depleted blue region. Here they find a very low electric field and can freely diffuse along the cathodes over a long distance, even some centimeters.



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Conclusions

98% of Anodes < 600 pA/cm²
WFM 8/20 40% Yield

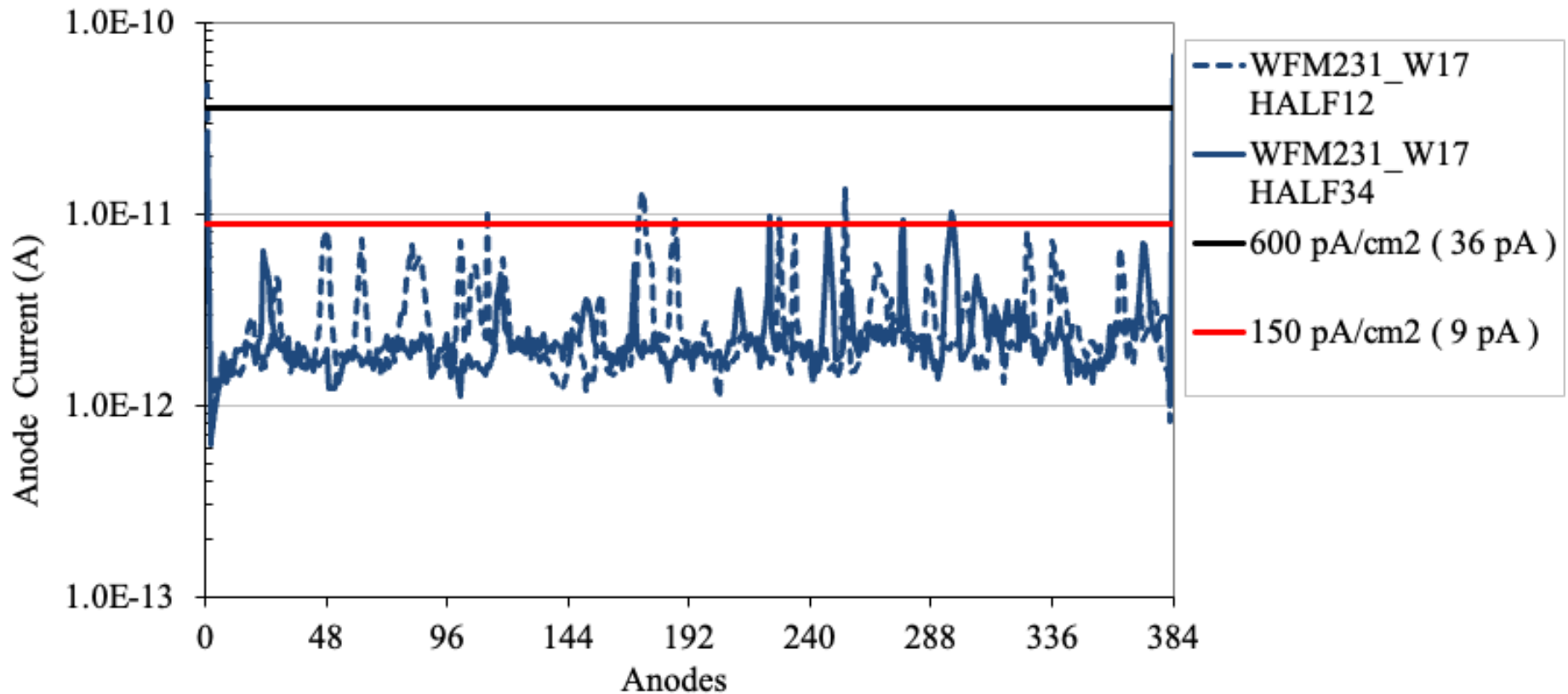
- We demonstrated the feasibility of producing large area SDDs with a reasonable yield for the eXTP WFM instrument.
- The fabrication process is able to produce the sensors with very low leakage currents
- We understand the factors limiting the yield and we plan to change the design to reduce effect of this factors.

Thank you

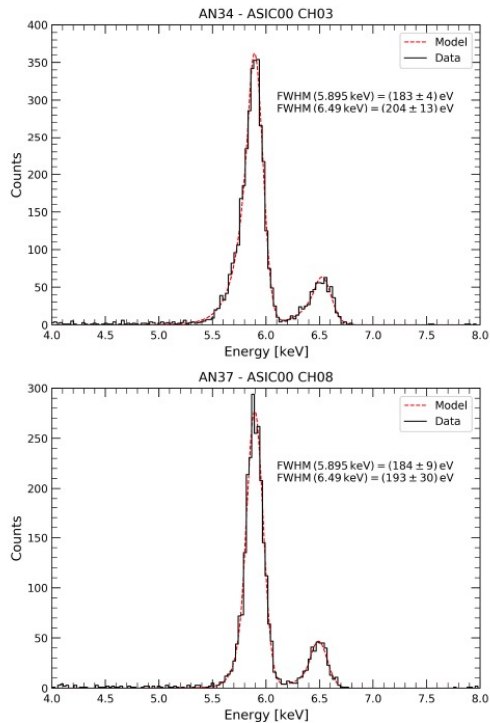
WFM 231 The best

$$\langle I \rangle = 43 \text{ pA/cm}^2 \quad (2.6 \text{ pA/anode })$$

99.6% of Anodes in SPEC of 600 pA/cm²
Only 3 lateral anodes are out of spec



Anode-wise spectral performance was evaluated by shielding the detector except for the anode region, and exposing it to X-rays from ^{55}Fe and ^{109}Cd . Tests were performed at 20 °C and 0°C in a climatic chamber, yielding a best resolution of **183 eV** and an average of 204 eV **at 5.9 keV at 0 °C**.



Sample single-anode spectra at 0 °C at 3.6 μs shaping time